

## Comment on “Photoreflectance study in the $E_1$ and $E_1 + \Delta_1$ transition regions of CdTe” [J. Appl. Phys. 87, 7360 (2000)]

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Kaneta and Adachi<sup>1</sup> have recently presented a photoreflectance (PR) study of CdTe in the region of the “ $E_1$ ” and “ $E_1 + \Delta_1$ ” transitions as a function of temperature in the range of 77–300 K. As is acknowledged in the article these optical features are primarily excitonic in nature; the PR line shape fits are relevant to excitonic features, i.e., the exponent  $n_j$  in Eq. (6) is taken to be 2.

The fact that the  $E_1$  and  $E_1 + \Delta_1$  optical transitions in diamond and zincblende semiconductors are mainly excitonic has been known for more than 30 years.<sup>2</sup> Therefore, as pointed out in Ref. 3 (an article that has been largely ignored) the energies of these features are not the critical point (CP) energies, as discussed in Ref. 1 and listed in Table I. These structures actually correspond to the CP energies minus the binding energy ( $R_1$ ) of the related two-dimensional exciton, i.e.,  $E_1 - R_1$  and  $(E_1 + \Delta_1) - R_1$ . Reference 3 and the work of Wei *et al.*<sup>4</sup> have shown that  $R_1$  in CdTe is quite substantial, i.e., about 150 meV.

As pointed out in a number of recent articles by the Brooklyn College group<sup>4–9</sup> the so-called  $E_1$  and  $E_1 + \Delta_1$  op-

tical transitions in these materials should actually be labeled  $E_1 - R_1$  and  $(E_1 + \Delta_1) - R_1$ , respectively.

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<sup>2</sup>See, for example, P. Y. Yu and M. Cardona, *Fundamentals of Semiconductors* (Springer, Heidelberg, 1996), and references therein.

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